Electron-phonon coupling and phonon dynamics in single-layer NbSe₂ on graphene: the role of moiré phonons

Amjad Al Taleb¹, Wen Wan², Giorgio Benedek^{2,3}, Miguel M. Ugeda^{2,4,5} and Daniel Farías^{1,6,7,*}

¹Departamento de Física de la Materia Condensada, Universidad Autónoma de Madrid, 28049 Madrid, Spain ² Donostia International Physics Center, Paseo Manuel de Lardizábal 4, 20018 San Sebastián, Spain.

³Dipartimento di Scienza dei Materiali, Università di Milano-Bicocca, 20125 Milano, Italy ⁴Ikerbasque, Basque Foundation for Science, 48013 Bilbao, Spain. ⁵Centro de Física de Materiales, Paseo Manuel de Lardizábal 5, 20018 San Sebastián, Spain.

⁶Instituto Nicolás Cabrera, Universidad Autónoma de Madrid, 28049 Madrid, Spain

⁷Condensed Matter Physics Center (IFIMAC), Universidad Autónoma de Madrid, 28049 Madrid, Spain

Abstract

The interplay between substrate interactions and electron-phonon coupling in twodimensional (2D) materials presents a significant challenge in understanding and controlling their electronic properties. Here, we present a comparative study of the structural characteristics, phonon dynamics, and electron-phonon interactions in bulk and monolayer NbSe₂ on epitaxial bilayer graphene (BLG) using helium atom scattering (HAS). High-resolution helium diffraction reveals a (9x9)0° superstructure within the NbSe₂ monolayer, commensurate with the BLG lattice, while out-of-plane HAS diffraction spectra indicate a low-corrugated ($3\sqrt{3} \times 3\sqrt{3}$) 30° substructure. By monitoring the thermal attenuation of the specular peak across a temperature range of 100 K to 300 K, we determined the electron-phonon coupling constant (λ_{HAS}) as 0.76 for bulk 2H-NbSe₂. In contrast, the NbSe₂ monolayer on graphene exhibits a reduced λ_{HAS} of 0.55, corresponding to a superconducting critical temperature (Tc) of 1.56 K according to the MacMillan formula, consistent with transport measurement findings. Inelastic HAS data provide, besides a set of dispersion curves of acoustic and lower optical phonons, a soft, dispersionless branch of phonons at 1.7 meV, attributed to the interface localized defects distributed with the superstructure period, and thus termed moiré phonons. Our data show that moiré phonons contribute significantly to the electron-phonon coupling in monolayer NbSe₂. These results highlight the crucial role of the BLG on the electronphonon coupling in monolayer NbSe₂, attributed to enhanced charge transfer effects, providing valuable insights into substrate-dependent electronic interactions in 2D superconductors.

I. Introduction

Layered transition-metal chalcogenides (TMD) are well-suited systems to study the effects of dimensionality and thickness on collective electronic phases like superconductivity and charge density waves (CDW). These are generally manifestations of electron-phonon interactions, leading to electron-electron (hole-hole) pairing and electron-hole ordering, respectively. Bulk 2H-NbSe₂ is especially interesting due to the coexistence of superconducting and CDW phases: a CDW with a (3x3) periodicity is known to set in below 33 K [1], while superconductivity sets in at $T_c = 7.2$ K [2]. In the monolayer NbSe₂ limit, different results have been reported depending on the supporting substrate. On epitaxial bilayer graphene (BLG) on SiC(0001), T_c is depressed to 1.5 K whereas the critical temperature for the appearance of the CDW remains unchanged (33 K) [3]. However, when the monolayer is hold on sapphire, superconductivity was observed to set in at $T_c = 3$ K, while the CDW critical temperature increases to 145 K [4]. These results were interpreted in terms of an increase in the electron-phonon coupling in single-layer NbSe₂/sapphire. Regarding charge transfer, there is little difference between sapphire (work function ~4.5 eV [5]) and BLG/SiC (work function 4.30 eV [6]), when compared to NbSe₂ work function of 5.9 eV [7]. Thus, these different behaviors in the

presence of similar charge transfer raise the question about the possible role of BLG underneath in both superconductivity and CDW and more specifically, on the strength of the electron-phonon coupling in single-layer NbSe₂.

In this work, we report measurements of the electron-phonon coupling constant (mass-enhancement factor) λ_{HAS} in single-layer NbSe₂/BLG/SiC(0001) by high-resolution helium atom scattering (HAS) spectroscopy [8], which enabled us to extract information about the surface structure on a long-period (nm) scale and related low-energy (meV) dynamics. Our He-diffraction results show that single-layer NbSe₂ on BLG develops a commensurate superstructure, where a (9x9) NbSe₂ monolayer supercell matches with a small tensile strain a (13x13) BLG supercell. A comparatively intense, dispersionless low-energy (1.7 meV) phonon branch is also observed. This effect induced by the superstructure on phonon dynamics is analogous to what observed in the electronic structure, like the occurrence of ultra-flat electronic bands, e.g., in twisted bilayers of WSe₂ [9] and of graphene [10,11], ultimately responsible for the observed superconductivity in in these heterostructures.

A recent quantum-theoretical approach showed how the thermal attenuation of the HAS specular peak from metal surfaces, described by the Debye-Waller (DW) exponent, can directly provide the electron-phonon coupling constant (mass-enhancement factor λ , here denoted λ_{HAS} when obtained with this method) [12] This method to derive λ_{HAS} has been recently extended to other classes of conducting surfaces, like those of layered TMDs [13,14] and supported graphene monolayers [15], and is here applied to the present NbSe₂ heterostructures to elucidate the role of the low-energy phonon branch in the electron-phonon coupling. In general, HAS spectroscopy should be relevant for the characterization of twisted layered heterostructures and their functional properties in the new area of *twistronics* [16].

II. Results and discussion

II.a) Diffraction

Figure 1(a) shows the HAS angular distribution measured for single-layer NbSe₂/BLG/SiC(0001) (red curve) along the (1000) direction, and is compared to that for a 2-3 layers of NbSe₂/BLG/SiC(0001) (green curve) and for the bulk NbSe₂(0001) surface (black curve), all recorded at T = 100 K. The spectrum for bulk NbSe₂ shows numerous intense diffraction peaks, indicating a highly corrugated surface, similar to those typically found on semiconductor surfaces. A comparable diffraction spectrum is observed for the few-layer sample, while the monolayer NbSe₂ exhibits a significantly different pattern. In this case, the diffraction intensities are much weaker than the specular scattering, suggesting a metallic surface for the monolayer due to significant charge transfer from the substrate. This is consistent with the comparatively large difference between the work function of bulk NbSe₂ (5.9 eV) [17] and that of few-layer NbSe₂/BLG (4.30 eV)[18].

The charge trasfer is also responsible of a small shift of the diffraction peaks of the NbSe₂ monolayer as compared to those of the bulk and few-layer samples. For the $(0\overline{1})$ diffraction the latter occur at $\theta_f = 39.5^\circ$, which gives an in-plane lattice constant a_N = 3.44 Å, in perfect agreement with the value measured in NbSe₂ multilayer flakes [19], while the $(0\overline{1})$ peak maximum for the monolayer is shifted to 39.9°. This corresponds to $a_N = 3.52$ Å, i.e., to a ~2.3% expansion of the in-plane monolayer lattice constant. The electronic charge transfer leaves behind a positive potential in the substrate and, therefore, a component in the surface charge density distribution reflecting the substrate periodicity. Actually, the ×4 magnification of the diffraction in the monolayer (Fig. 1(b)) hints to a maximum around $\theta_f = 33^\circ$, where the BLG (01) diffraction peak is expected to occur for the known graphene lattice parameter of 2.46 Å [20,21].



Figure 1. (a) Angular distribution of HAS along the (10) direction (Γ M) of the surfaces of bulk NbSe₂(0001) (black curve), few-layer NbSe₂/BLG/SiC(0001) (green curve) and single-layer NbSe₂/BLG/SiC(0001) (red curve). The angle of incidence is 60° and the incident energy of the He beam is $E_i = 44$ meV. (b) A factor-4 expansion of the diffraction spectrum for the monolayer NbSe₂, where the BLG(01) diffraction peak is also visible, as an effect of the charge transfer.

The observation of the diffraction peaks of both the monolayer NbSe₂ and the BLG substrate induced by a large charge transfer is confirmed by the high-resolution HAS

diffraction pattern displayed in Fig. 2. The $(0\bar{1})$ BLG diffraction peak at $\varphi = -22.1^{\circ}$ is about one half in size as that of single-layer NbSe₂ at $\varphi = -15.2^{\circ}$ and comparable in sharpness, and corresponds to the in-plane lattice constants $a_{BLG} = 2.47 \pm 0.02$ Å and a_N $= 3.55 \pm 0.02$ Å. This value of a_N confirms the in-plane expansion (here $3.2 \pm 0.6\%$) of the NbSe₂ monolayer with respect to the bulk induced by the charge transfer.



Figure 2. High-resolution HAS angular distribution measured as a function of the rocking angle (top-left inset) along the (10) direction (Γ M) of single-layer NbSe₂/BLG/SiC(0001) at T = 100 K, with a fixed scattering angle of 108° and incident energy of 23 meV. The upper part of the figure shows the corresponding diffraction spots in the reciprocal space

of single-layer NbSe₂ (black dots) and those near the specular peak of the single-layer NbSe₂/BLG superstructures indicated in the top-right inset and discussed in the text.

Since the diffraction components of both the single-layer NbSe₂ and BLG are observed in Fig. 2, the small features at $\varphi \cong -5^\circ$, -3.3° , -1.7° and 5° near the specular peak and discernible above the noise (especially in the filtered data, red line), is assigned to a commensurate superstructure with a unit cell aligned with those of the two component lattices. The lattice constant ratio $a_N / a_{BLG} = 1.44$ is very close to $13/9 = 1.\overline{4}$, suggesting that the hexagonal superlattice unit cell is fromed by the coincidence of a $(9\times9)0^\circ$ cell of the NbSe₂ monolayer with a $(13\times13)0^\circ$ cell of BLG. This is illustrated by Fig. 3(a), which shows the interface Se ions (green atoms) positioned over the graphene (grey atoms), with the superlattice unit cell edges marked in red. The corresponding theoretical diffraction spots around the origin (specular peak) in the reciprocal plane are shown in the upper part of Fig. 2 (red and green dots), with some spots closely corresponding to the small features described above.



Figure 3. (a) Structure of the single-layer NbSe₂/BLG interface showing the Se ions (green full circles) on graphene (grey C atoms). The red lines show the unit cell of the single-layer NbSe₂ (9×9)0° supercell matching the $(13\times13)0°$ supercell of BLG. (b) The reduced $(3\sqrt{3}\times3\sqrt{3})30°$ unit cell of single-layer NbSe₂ (green contour line) in case of equivalence between the BLG high-symmetry hexagonal sites (left and right corners of the reduced cell) and the trigonal symmetry sites (top and bottom corners), approximately produced by the addition of the second BLG graphene layer (not shown).

The presence of a second graphene layer underneath causes the Se ions at the hexagonal symmetry sites (e.g., the corners of the $(9\times9)0^{\circ}$ unit cell in Fig. 3(a)) to be almost equivalent, in terms of adsorption energy, to those at the trigonal symmetry sites (e.g., the top and bottom atoms of the reduced $(3\sqrt{3}\times3\sqrt{3})30^{\circ}$ unit cell, as shown in Fig. 3(b)). If these sites were strictly equivalent, the actual $(3\sqrt{3}\times3\sqrt{3})30^{\circ}$ supercell would be three times smaller, and only the diffraction peaks corresponding to the green spots in

Fig. 2 would appear. However, even with approximate equivalence, the green spots—especially the first six, which form a 30° rotated hexagon in Fig. 2—are reinforced.

Out-of-plane measurements made using the HAS confirm this effect. The HAS intensity, mapped as a function of the final angle θ_f and out-of-plane azimuth angle φ_f for a fixed incident energy $E_i = 56$ meV and incident angle $\theta_i = 60^\circ$ (see Fig. 4(b); kinematics explained in Fig. 4(a)), shows maxima at the expected positions for the $(3\sqrt{3}\times3\sqrt{3})30^\circ$ supercell (green hexagons). Note that the hexagonal pattern is slightly rotated clockwise relative to the calculated maxima positions, due to a minor azimuthal misalignment of the NbSe₂ lattice with respect to the sagittal plane $\varphi_i = 0^\circ$ (see Fig. SI-1 for details). However, this small instrumental misalignment does not undermine the strong evidence supporting the $(3\sqrt{3}\times3\sqrt{3})30^\circ$ supercell as the approximate commensurate structure for single-layer NbSe₂/BLG/SiC(0001).

It is worth mentioning that essentially the same diffraction spectra for the NbSe₂ monolayer, including the out-of-plane map demonstrating the $(3\sqrt{3}\times3\sqrt{3})30^{\circ}$ superlattice, have been measured at T = 40 K (see Fig. SI-1), which indicates that there is no evidence for a (3x3) CDW pattern above 40 K. This is in agreement with previous STM results on the same system, which showed that a CDW sets in below 35 K [3], and in clear contrast with previous Raman measurements using samples exposed to ambient conditions where $T_C = 145$ K [4].



Figure 4. (a) Geometry and kinematics of out-of-plane HAS diffraction relating the components of the final parallel wavevector \mathbf{K}_{i} and parallel wavevector transfer $\Delta \mathbf{K}$ to the incident wavevector \mathbf{k}_{i} (or incident energy through $k_{i}[\text{Å}^{-1}] = 1.383\sqrt{E_{i}}[\text{meV}]$ for ⁴He atoms [8]) and scattering geometry. (b) The out-of-plane HAS diffraction map of single-layer NbSe₂/BLG/SiC(0001) at T = 40 K, measured as a function of the final and azimuthal angles defined in (a) at a fixed incident angle of 60° and energy of 52 meV. The 30°-rotated hexagonal pattern reflects the theoretical positions of the diffraction peaks (green hexagonal dots) for the $(3\sqrt{3}\times3\sqrt{3})30^{\circ}$ superlattice.

II.b) The Debye-Waller exponent

Figure 5 shows the temperature dependence of the Debye-Waller exponent, as derived from the ratio of He specular intensity at the surface temperature T, $I(T) \equiv I$, to that at the lowest measured temperature T_0 , $I(T_0) \equiv I_0$, for single-layer NbSe₂ compared to the data for bulk NbSe₂ and the few-layer NbSe₂. The data for the NbSe₂ overlayers are reported for two different He beam incident energies and angles.



Figure 5. Thermal attenuation of He-specular intensity measured along the Γ M azimuth from bulk NbSe₂ (top), few-layer NbSe₂/BLG/SiC(0001) (middle), and for single-layer NbSe₂/BLG/SiC(0001) (bottom). Note the different ordinate scales for the three sets of data. The corresponding incident energy and incident angles are given for each set of data. The straight lines correspond to the best linear fits according to Eq. (2).

While the exponential attenuation of the specular intensity is about the same for the semi-infinite crystal and for the 2-3 layers, a much steeper attenuation is observed for the NbSe₂ monolayer on top of the graphene bilayer. This is mainly due to the graphene substrate, which provides several intervalley channels, as discussed in previous HAS studies on the electron-phonon interaction of graphene on various substrates [15]. In the next subsection, the corresponding values of the electron-phonon coupling constant are derived for the present set of data, based on the information from phonon dispersion curves derived from HAS time-of-flight (TOF) data. While HAS data for bulk NbSe₂ phonons are already available [22] and assumed to be approximately valid for multilayers, the HAS phonon data for the monolayer NbSe₂ are presented in the following subsection.



Figure 6. (a,b) Selected time-of-flight spectra measured with HAS at constant scattering angle $\theta_i + \theta_f = 108^\circ$, incident energy $E_i = 26$ meV, along the Γ M direction of single-layer NbSe₂/BLG at 100 K; each spectrum is labelled by the rocking angle φ of the surface plane, so that $\theta_i = 54^\circ + \varphi$ and $\theta_f = 54^\circ - \varphi$. (c) The corresponding phonon dispersion

curves (full black circles, with full grey lines as eye guidelines) are compared to those measured with HAS for the semi-infinite NbSe₂(0001) surface at room temperature (red open symbol [22], and to the bulk NbSe₂ dispersion curves (blue broken lines) [23]. Besides the surface branches S₁, S₃, S₄^v and S₄^h, a flat soft branch S₀ is observed in singlelayer NbSe₂/BLG at 1.7 meV, attributed to interface localized (moiré) modes with vertical (z) polarization. The horizontal (x-polarized) counterpart is associated with the S_x branch at 8 meV, which converts via avoided crossing to the S₃ branch at about Γ M/2. The displacement patterns of the atomic planes for the different branches are schematically shown in (d), with the BLG illustrated by blue segments, the NbSe₂ three atomic layers by grey and black segments, and the SiC(0001) substrate, assumed to be rigid, by grey boxes.

II.c) Phonons

Two of the several sets of HAS TOF spectra of 1ML-NbSe₂/BLG/SiC(0001), measured at a surface temperature of 100 K along the Γ M direction, are shown in Figs. 6(a,b) as functions of the energy transfer ΔE_i . The inelastic peaks in the TOF spectra, like those marked by small triangles in Figs. 6(a,b) for phonon creation ($\Delta E_i < 0$) and annihilation ($\Delta E_i > 0$) processes, provide the phonon energy $\hbar \omega = |\Delta E_i|$ as a function of the parallel wavevector $Q = |\Delta K|$ (full black circles in Fig. 6c). A possible set of dispersion curves is represented by the eye-guidelines (gray full lines) drawn in Fig. 6(c). They are compared to the data for the 2H-NbSe₂(0001) surface (red open symbols) [22] and to the bulk NbSe₂ dispersion curves (blue broken lines) [23].

In the long-wave limit the surface phonon branches in the acoustic region of 1ML-NbSe₂/BLG labelled as S_1 , S_3 , S_4^{v} and S_4^{h} correspond to the Rayleigh wave, the

longitudinal resonance, the shear-vertical and longitudinal oscillations of the NbSe₂ monolayer against the BLG (Fig. 6(d)). In 2H-NbSe₂(0001) the surface unit cell includes two NbSe₂ monolayers, while in our system the BLG plays, to some extent, the role of the second monolayer. This may alone explain the softening of the S₁ branch and the stiffening of S₃, both in the second half of Γ M, with respect to those of bulk 2H-NbSe₂(0001) (red open symbols), although the stiffening of S₃ may also be related to the avoided crossing with S_x. Note that a possible Kohn anomaly occurs in the S₁ branch near 0.6 Å⁻¹, more pronounced than that found with HAS at room temperature in bulk NbSe₂(0001) [22], and showing a shift to a smaller *Q* with respect to that reported with neutron scattering in bulk at ²/₃ Γ M (blue broken line) [23]. This is probably related to the anomaly has been observed with HAS in 2H-TaSe₂(0001) for the Rayleigh mode with respect to the anomaly in the bulk acoustic mode [24].

The low-energy flat phonon branch S_0 , displaying a strong intensity at small Q (Figs. 6(a.b)) may be associated to soft shear-vertical vibrations localized at a superlattice periodic array of atoms, for example the interface Se ions which accommodate at the high symmetry hexagonal (and possibly trigonal) sites of graphene (corner atoms in Fig. 3(b)) with strongly weakened local shear force constants. Note that this branch is reminiscent of the low energy dispersionless modes observed on Gr/Ir(111) and Gr/Ru(0001), where graphene builds a moiré pattern [25,26]. Due to this analogy and the present interpretation of the flat branch as closely associated with the interface superstructure, in the following discussion we shall term these localized excitations as *moiré* phonons. On the other hand, such localized shear vertical vibrations should have their longitudinal companion, which is here associated with the S_x additional branch, also localized above the maximum of the acoustic band in the region around the zone center [27]. Clearly, only a surface dynamics

first-principle calculation for this system would allow for a reliable assignment of the observed additional moiré branches S_0 and S_x .

II.d) Electron-phonon interaction

The HAS data for ln(I/I₀), shown in Fig. 5 for the surfaces studied, provide the HAS Debye-Waller (DW) exponent -2W(T), up to a constant that depends on how I₀ is defined. Therefore, the slope of ln(I/I₀) as a function of temperature directly represents the slope of -2W(T), regardless of the specific definition of I₀. This slope can be used to determine the electron-phonon coupling constant, λ_{HAS} (also known as the mass-enhancement factor), for bulk NbSe₂ and the few-layers. This approach is based on the method valid in the high-temperature limit [12].



Figure 7. Fits of the Debye-Waller data for HAS incident energy $E_i = 43$ meV and angle $\theta_i = 60^\circ$ using Eq. (1). The red curve represents a fit including only the moiré phonons contribution (A = 1), the blue curve represents an equal share of the moiré and the NbSe₂ phonons (A = 0.5) and the grey curve includes only the NbSe₂ ML phonons (A = 0). The few data for $E_i = 22$ meV and $\theta_i = 52.7^\circ$, all above 125 K, are well fitted by the high-*T* straight line, independently of *A*.

For single-layer NbSe₂/BLG/SiC, at least two different contributions to λ_{HAS} are expected from phonons from the NbSe₂ monolayer and moiré phonons from the interface. The high-energy optical phonons of the BLG can be neglected, however, due to their small population in the present temperature range, and their depth beneath the first surface atomic layer. In this approximation, the expression of the DW exponent receiving contributions from two distinct phonon spectral regions can be written as in Ref. [28]

$$2W(\mathbf{k}_{i},T) = \frac{a_{c}k_{iz}^{2}}{\pi\phi}n_{s}\lambda_{HAS}\left\{A\hbar\omega_{0}\operatorname{coth}\left(\frac{\hbar\omega_{0}}{2k_{B}T}\right) + (1-A)\hbar\omega_{1}\operatorname{coth}\left(\frac{\hbar\omega_{1}}{2k_{B}T}\right)\right\},\tag{1}$$

where $\omega_0 = 1.7$ meV and $\omega_1 = 13.5$ meV are the frequency of moiré phonons and the surface Debye frequency of bulk NbSe₂ (taken as the bulk Debye frequency [29] divided by $\sqrt{2}$ [8]), respectively, and the coefficient $0 \le A \le 1$ weighs the two contributions. In the prefactor of Eq. (1) r.h. member, a_c is the surface unit cell area, equal to 10.276 Å² for the semi-infinite bulk NbSe₂ [30] and for the few layers, while for single-layer NbSe₂ the value $a_c = 10.914$ Å² is determined from the measured lattice parameter including the dilation induced by charge transfer. Moreover, k_{iz} is the surface normal component of the incident He atom wavevector, n_s the effective number of conducting layers (including multivalley transition multiplicity [15]) contributing to the surface electron-phonon interaction, and ϕ the surface workfunction. For the semi-infinite bulk NbSe₂, $\phi = 5.9$

eV [31] and $n_s = 2$, as used for 2H-stacked TMDs [13,14,32]. For few-layer NbSe₂ it is also $n_s = 2$, but the robust charge transfer from the SiC to NbSe₂ lowers the workfunction to that of the latter, $\phi = 4.6$ eV [18]. For the NbSe₂ monolayer ($n_s = 1$) on BLG ($n_s = 6$ [15]) a total $n_s = 7$ is used, together with the workfunction of the gBLG/SiC(0001), $\phi =$ 4.3 eV [18]. For a given value of *A*, the mass-enhancement factor λ_{HAS} is used as a free parameter so as to obtain the best fit of the -2W(T) shape (equal to that of $\ln(I(T)/I_0)$). In this way λ_{HAS} is obtained. The high-temperature limit is equivalent to let ω_0 and ω_1 in Eq. (1) tend to zero, which gives

$$2W(\mathbf{k}_{i},T) = \frac{2a_{c}k_{iz}^{2}}{\pi\phi}n_{s}\lambda_{HAS}k_{B}T \quad , \tag{2}$$

and therefore

$$\lambda_{HAS} = -\frac{\pi\phi}{2n_s a_c k_{iz}^2} \frac{\partial \ln[I(T)/I_0]}{k_B \partial T} , \qquad (3)$$

as reported in [12].

The best linear fits in the high-*T* limit (Eq. 2) for all the considered samples are shown in Fig. 5 (straight lines) and give $\lambda_{HAS} = 0.76$ for semi-infinite bulk NbSe₂, $\lambda_{HAS} = 0.82 \pm 0.06$ and 0.75 ± 0.06 for the 2-3ML-NbSe₂ data sets $43 \text{meV}/65^\circ$ ($k_{iz}^2 = 14.75 \text{ Å}^{-2}$) and $36 \text{meV}/60^\circ$ ($k_{iz}^2 = 17.28 \text{ Å}^{-2}$), respectively. For the NbSe₂ monolayer on BLG/SiC the fit gives $\lambda_{HAS} = 0.58 \pm 0.04$ or 0.63 ± 0.04 when measured with a 43 meV He beam at 60° incidence or with a 22 meV He beam at 52.7° incidence, respectively.

As discussed above in connection with Eq. (1), the λ_{HAS} for the two data sets of single-layer NbSe₂ actually receives contributions from two distinct phonon spectral

regions: moiré phonons and the lattice dynamics of the NbSe₂ layer. Figure 7 shows three fits based on Eq. (1) of the 43meV/60° data, one with only the moiré phonons contribution (A = 1), one with an equal share of the moiré and the NbSe₂ phonons (A = 0.5) and the third with only the NbSe₂ monolayer phonons (A = 0). The two fits including NbSe₂ phonons (A = 0.5, 0) yield both $\lambda_{HAS} = 0.60 \pm 0.04$, which is consistent with the high-T limit for the 43 meV/60° data. All three fits adequately account quite well for the experimental slope above 150 K, where the high-T linearity is established. However, below this temperature the two fits for $A \neq 0$ diverge from the one including only moiré phonons and from experiment. This suggests that the moiré phonons make a significant contribution to the electron-phonon interaction at low temperatures. In a sense, they serve as acoustic surface modes that exist in bulk NbSe₂, but lose their character and localization at small ΔK in the film due to penetration into the much stiffer substrate. This specific role of the moiré phonons, which preserve their localization also for $Q \rightarrow 0$, is consistent with the observation that the moiré phonons are detected by HAS in those regions of the parallel momentum transfer where they intersect the S₁ and S₃ branches.

The above values of λ_{HAS} in few-layer NbSe₂ are only slightly larger than the value found for bulk NbSe₂, $\lambda = 0.8$. These values are in the range of the theoretical value for the monolayer reported [33], $\lambda = 0.67$, but smaller than the values calculated for two different CDW configurations ($\lambda = 0.84$ and 1.09) [34]. They also agree with the experimental value $\lambda = 0.75$ from electrical transport and optical measurements for NbSe₂ monolayer on sapphire (work function 4.5 eV), but strongly disagree for the bilayer value of $\lambda = 0.33$ [4] and with the values for the bulk NbSe₂ [35,36], $\lambda = 0.15$. On the other hand, low-temperature photoemission measurements report $\lambda \cong 0.85 \pm 0.15$ for bulk NbSe₂ [37].

II.e) Superconducting critical temperature

The superconducting critical temperature Tc can be derived from λ_{HAS} via the Allen–Dynes-modified McMillan formula [38,39]

$$T_{c} = 11.5 \frac{\kappa}{meV} \left\langle \omega \right\rangle_{meV} \exp\left[-\frac{1.04(1+\lambda_{HAS})}{\lambda_{HAS} - \mu^{*} - 0.62\lambda_{HAS}\mu^{*}}\right],\tag{4}$$

with the Coulomb pseudopotential $\mu^* = 0.15$ and $\langle \omega \rangle_{meV} = 12.61$ meV taken from [35]. For the bulk NbSe₂ ($\lambda_{HAS} = 0.76 \pm 0.03$) it is found $T_c = 4.9 \pm 0.6$ K, which is smaller than the bulk value. Comparable values of T_c are found from the two sets of data for few-layer NbSe₂ (6.0 ± 0.7 K from $\lambda_{HAS} = 0.82 \pm 0.06$ and 4.7 ± 0.6 K from $\lambda_{HAS} = 0.75 \pm 0.06$) when the same values of μ^* and $\langle \omega \rangle_{meV}$ are used for the NbSe₂ multilayers. Encapsulated NbSe₂ multilayers with $2 \le n \le 8$ have shown a uniform decrease of T_c with thickness just in that range, while the T_c of the monolayer encapsulated with hBN drops to 2 K [40].

For monolayer NbSe₂ (curve labelled 43meV/60° in Fig. 7), the best fit value λ_{HAS} = 0.58 ± 0.04, obtained by including the moiré phonons (A = 1), yields, for $\langle \omega \rangle_{meV} = 12.61$ meV, a smaller value of T_c , equal to 1.84 ± 0.20 K. This compares well with previous experimental T_c values obtained for single-layer NbSe₂/BLG/SiC using STM/STS ($T_c =$ 1.5 K) [41] and transport measurements $T_c = 1.5$ K [42]. Despite the possible contributions of the moiré phonons, the graphene interfacing has apparently the effect of depressing superconductivity.

III. Conclusions

High-resolution HAS diffraction data from single-ayer NbSe₂ on BLG/SiC(0001) reveal a $(9\times9)0^{\circ}$, approximately reducible to a $(3\sqrt{3}\times3\sqrt{3})30^{\circ}$ superstructure,

commensurate with the underlying BLG lattice. Inelastic HAS data provide, besides a set of dispersion curves of acoustic and lower optical phonons, a soft, dispersionless branch of phonons at 1.7 meV, attributed to the interface localized defects distributed with the superstructure period, and thus termed moiré phonons. The electron-phonon coupling for single-layer NbSe₂/BLG has been derived from the temperature dependence of the DW exponent, and compared with those of few-layer NbSe₂/BLG/SiC(0001) and bulk NbSe₂. The low-temperature behavior of the DW exponent suggests an appreciable contribution of the moiré phonons to the electron-phonon coupling, although the intercalation of the BLG between the NbSe₂ monolayer and the SiC substrate is seen to attenuate the electronphonon coupling with respect to the case of a NbSe₂ monolayer directly deposited on an inert substrate.

In conclusion, it has been demonstrated that high-resolution HAS diffraction studies can be advantageously extended to long-period conducting surfaces, e.g., those exhibiting long-period superstructures, in order to obtain a detailed structural information. Moreover, the electron-phonon interaction obtained from the analysis of the HAS-DW factor as a function of temperature proves to be, within the experimental uncertainties, quite reliable, also in the case of particularly complex superconducting 2D structures. The growing interest in twisted moiré structures, realized through the assembling of 2D layered materials, should find in HAS a valuable tool for their structural and dynamical characterization.

Supporting Information

Supporting informations is available, containing additional experimental details and complementary results.

Corresponding Author

* Prof. Daniel Farías

Dpto. de Física de la Materia Condensada Universidad Autónoma de Madrid

28049 Madrid, SPAIN

Phone: +34 91 497 5550 Fax: +34 91 497 3961

daniel.farias@uam.es

Author Contributions

The manuscript was written through contributions of all authors. All authors have given approval to the final version of the manuscript.

Acknowledgements

This work has been partially supported by the Spanish Ministerio de Ciencia e Innovación under projects PID2019-109525RB-I00 and PID2023-147466OB-C21. D.F. acknowledges financial support from the Spanish Ministry of Economy and Competitiveness, through the "María de Maeztu" Programme for Units of Excellence in R&D (CEX2018-000805-M). M.M.U. acknowledges support by the ERC Starting grant LINKSPM (Grant 758558) and by the Spanish grant no. PID2020-116619GB-C21 funded by MCIN/AEI/10.13039/501100011033.

References

[1] Michio Naito and Shoji Tanaka, *Electrical Transport Properties in 2H-NbS*₂, -*NbS*₂,
-*TaS*₂ and -*TaS*₂, J. Phys. Soc. Jpn. **51**, 219 (1982).

[2] Foner, S. & McNiff, E. J. Upper critical fields of layered superconducting NbSe2 at low temperature. Phys. Lett. A 45, 429–430 (1973).

[3] M. M. Ugeda, A. J. Bradley, Y. Zhang, S. Onishi, Y. Chen, W. Ruan, C. Ojeda-Aristizabal, H. Ryu, M. T. Edmonds, H.-Z. Tsai, A. Riss, S.-K. Mo, D. Lee, A. Zett, Z. Hussain, Z.-X. Shen, and M. F. Crommie, *Characterization of collective ground states in single-layer NbSe2*, Nat. Phys. **12**, 92 (2016).

[4] X. Xi, L. Zhao, Z. Wang, H. Berger, L. Forró, J. Shan, and K. F. Mak, *Strongly* enhanced charge-density-wave order in monolayer NbSe₂, Nat. Nanotech. 10,765 (2015).

[5] W. I. Semov, Work Function of Oxidized Metal Surfaces and Estimation of A1₂0₃ Film
 Band Structure Parameters, phys. stat. sol. 32, K41 (1969).

[6] S. Mammadov, J. Ristein, J. Krone, Ch. Raidel, M. Wanke, V. Wiesmann, F. Speck and T. Seyller, *Work function of graphene multilayers on SiC(0001)*, 2D Mater. **4**, 015043 (2017).

[7] T. Shimada, F. S. Ohuchi, and B. A. Parkinson, *Work Function and Photothreshold* of Layered Metal Dichalcogenides, Jpn. J. Appl. Phys. **33**, 2696 (1994).

[8] G. Benedek and J.P. Toennies, *Atomic-Scale Dynamics at Surfaces - Theory and Experimental Studies with Helium Atom Scattering*, (Springer-Nature, 2018).

[9] E. Li, J.X. Hu, X. Feng, Z. Zhou, L. An, K. T. Law, N. Wang and N. Lin, *Lattice reconstruction induced multiple ultra-flat bands in twisted bilayer WSe*₂, Nat. Commun. **12**, 5601 (2021).

[10] S. Lisi, X. Lu, T. Benschop, T. A. de Jong, P. Stepanov, J. R. Duran, F. Margot, I.Cucchi, E. Cappelli, A. Hunter, A. Tamai, V. Kandyba, A. Giampietri, A. Barinov, J.Jobst, V. Stalman, M, Leeuwenhoek, K. Watanabe, T. Taniguchi, L. Rademaker, S. J.

van der Molen, M. P. Allan, D. K. Efetov, and F. Baumberger, *Observation of flat bands in twisted bilayer graphene*, Nat. Phys. **17**, 189 (2021).

[11] H. S. Arora, R. Polski, Y. Zhang, A. Thomson, Y. Choi, H. Kim, Z. Lin, I. Z. Wilson, X. Xu, J.-H. Chu, K. Watanabe, T. Taniguchi, J. Alicea, and S. Nadj-Perge, *Superconductivity in metallic twisted bilayer graphene stabilized by WSe2*, Nature **583**, 379 (2020).

[12] J. R. Manson, G. Benedek, S. Miret-Artés, "Atom scattering as a probe of the surface electron-phonon interaction at conducting surfaces" Surf. Sci. Rep. **77**,100552 (2022).

[13] G. Anemone, M. Garnica, M. Zappia, P. Casado Aguilar, A. Al Taleb, C.-N. Kuo,
C. S. Lue, A. Politano, G. Benedek, A. L. Vàzquez de Parga, R. Miranda, and D. Farìas, *Experimental determination of surface thermal expansion and electron-phonon coupling constant of 1T-PtTe2*, 2D Materials 7, 025007 (2020).

[14] G. Anemone, P. Casado Aguilar, M. Garnica, F. Calleja, A. Al Taleb, C.-N. Kuo, C. S. Lue, A. Politano, A. L. Vàzquez de Parga, G. Benedek, D. Farìas, and R. Miranda, *Electron-phonon coupling in superconducting 1T-PdTe*₂, npj 2D Materials and Applications *5*, 25 (2021).

[15] G. Benedek, J. R. Manson, and S. Miret-Artés, *The Electron-Phonon Coupling Constant for Single-Layer Graphene on Metal Substrates Determined from He Atom Scattering*, PCCP 23, 7553 (2021).

[16] R. Ribeiro-Palau, C. Zhang, K. Watanabe, T. Taniguchi, J. Hone, C. R. Dean, *Twistable electronics with dynamically rotatable heterostructures*, Science **361**, 690 (2018). [17] T. Shimada, F. S. Ohuchi, B. A. Parkinson, *Work function and photothreshold of layered transition metal dichalcogenides*, Jpn. J. Appl. Phys. **33**, 2696 (1994).

[18] S. Mammadov, J. Ristein, J. Krone, Ch. Raidel, M. Wanke, V. Wiesmann, F. Speck, and T. Seyller, *Work function of graphene multilayers on SiC(0001)*, 2D Mat. 4, 015043 (2017).

[19] T. Zhu, P. M. Litwin, M. G. Rosul, D. Jessup, M. S. Akhanda, F. F. Tonni, S. Krylyuk, A. V. Davydov, P. Reinke, S. J. McDonnell, M. Zebarjadi* *Transport properties* of few-layer NbSe2: From electronic structure to thermoelectric properties, Mat. Today Phys. 27, 100789 (2022).

[20] G. Yang, L. Li, W. B. Lee, and M. C. Ng, *Structure of graphene and its disorders: a review*, Sci. Technol. Adv. Mater. 19, 613-648 (2018)

[21] E. McCann and M. Koshino, *The electronic properties of bilayer graphene*, Rep. Prog. Phys. 76, 056503 (2013).

[22] G. Benedek, J. R. Manson, S. Miret-Artés, A. Ruckhofer, W. E. Ernst, A. Tamtögl, and J. P. Toennies, *Measuring the Electron-Phonon Interaction in Two-Dimensional Superconductors with He Atom Scattering*, Condens. Matter **5**, 79 (2020); corr.: **6**, 54 (2021).

[23] D. E. Moncton. J. D. Axe, F.J. Di Salvo, Phys. Rev. B, 16, 801 (1977).

[24] G. Benedek, G. Brusdeylins, C. Heimlich, L. Miglio, J. Skofronick, and J.P. Toennies, *Shifted Surface Phonon Anomaly in 2H-TaSe2(001)*, Phys. Rev. Letters <u>60</u>, 1037 (1988).

[25] A. Al Taleb, G. Anemone, D. Farías, and R. Miranda, *Resolving localized phonon modes on graphene/Ir(111) by inelastic atom scattering*, Carbon 133, 31 (2018).

[26] D. Maccariello, D. Campi, A. Al Taleb, G. Benedek, D. Farías, M. Bernasconi, R.Miranda, *Low-energy excitations of graphene on Ru(0001)*, Carbon, **93**, 1 (2015).

[27] F. Weber, R. Hott, R. Heid, K.-P. Bohnen, S. Rosenkranz, J.-P. Castellan, R. Osborn,
A. H. Said, B. M. Leu, and D. Reznik, *Optical phonons and the soft mode in 2H-NbSe*₂,
Phys. Rev. B 87, 245111 (2013).

[28] G. Benedek, J. R. Manson, S. Miret-Artès, *The Role of High-Energy Phonons in Electron-Phonon Interaction at Conducting Surfaces with Helium-Atom Scattering*, PCCP 24, 23135 (2022).

[29] J. M. E. Harper, T. H. Geballe, and F. J. DiSalvo, *Thermal properties of layered transition-metal dichalcogenides at charge-density-wave transitions*, Phys. Rev. B 15, 2943 (1977).

[30] M. Marezio, P.D. Dernier, A. Menth, G.W. Hull Jr., *The crystal structure of NbSe₂ at 15°K*, J. Sol. St. Chem. 4, 425 (1972).

[31] T. Shimada, F. S. Ohuchi and B. A. Parkinson, *Work Function and Photothreshold* of Layered Metal Dichalcogenides, Japan J. Appl. Phys. 33, 2696 (1994).

[32] G. Anemone, A. Al Taleb, G. Benedek, A. Castellanos-Gomez, and D. Farías, *Electron-Phonon Coupling Constant of MoS*₂", J. Phys. Chem. C 123. 3682-3686 (2019)

[33] F. Zheng and J. Feng, *Electron-phonon coupling and the coexistence of superconductivity and charge-density wave in monolayer* NbSe₂, Phys. Rev. B 99, 161119 (2019). [34] C.-S. Lian, C. Si, and W. Duan, *Unveiling Charge-Density Wave, Superconductivity, and Their Competitive Nature in Two-Dimensional NbSe*₂, Nano Lett. 18, 2924 (2018).

[35] K. Rossnagel, On the origin of charge-density waves in select layered transitionmetal dichalcogenides, J. Phys. Cond. Matt. 23, 213001 (2011).

[36] D. J. Rahn, S. Hellmann, M. Kalläne, C. Sohrt, T. K. Kim, L. Kipp, and K. Rossnagel,

Gaps and kinks in the electronic structure of the superconductor 2H-NbSe₂ from angleresolved photoemission at 1 K, Phys. Rev. B 85,224532 (2012).

[37] T. Valla, A. V. Fedorov, P. D. Johnson, P-A. Glans, C. McGuinness, K. E. Smith, E. Y. Andrei, and H. Berger, *Quasiparticle Spectra, Charge-Density Waves, Superconductivity, and Electron-Phonon Coupling in 2H–NbSe*₂, Phys. Rev. Lett. **92**, 086401 (2004).

[38] W.L. McMillan, *Transition Temperature of Strong-Coupled Superconductors*, Phys.Rev. 167, 331 (1968).

[39] R.C. Dynes, *McMillan's equation and the Tc of superconductors*, Sol. St. Comm.10, 615 (1992).

[40] Y. Cao *et al*, *Quality Heterostructures from Two-Dimensional Crystals Unstable* in Air by Their Assembly in Inert Atmosphere, Nano Lett. 15, 4914 (2015).

[41] W. Wan, P. Dreher, D. Muñoz-Segovia, R.Harsh, H. Guo, A.J. Martínez-Galera, F. Guinea, F.o de Juan and M.M. Ugeda, *Observation of Superconducting Collective Modes fromCompeting Pairing Instabilities in Single-Layer NbSe*₂, Advanced Materials 34, 2206078 (2022).

[42] Y. Nakata, K. Sugawara, S. Ichinokura, Y. Okada, T. Hitosugi, T. Koretsune, K. Ueno, S. Hasegawa, T. Takahashi, and T. Sato, *Anisotropic band splitting in monolayer NbSe₂: implications for superconductivity and charge density wave*, npj 2D Mat. Appl. *12*, 1-6 (2018).

Supplementary Information

Electron-phonon coupling and phonon dynamics in singlelayer NbSe₂: the role of moiré phonons

Amjad Al Taleb¹, Wen Wan², Giorgio Benedek^{2,3}, Miguel M. Ugeda^{2,4,5} and Daniel Farías^{1,6,7}

¹Departamento de Física de la Materia Condensada, Universidad Autónoma de Madrid, 28049 Madrid, Spain
 ² Donostia International Physics Center, Paseo Manuel de Lardizábal 4, 20018 San Sebastián, Spain.
 ³Dipartimento di Scienza dei Materiali, Università di Milano-Bicocca, 20125 Milano, Italy
 ⁴Ikerbasque, Basque Foundation for Science, 48013 Bilbao, Spain.
 ⁵Centro de Física de Materiales, Paseo Manuel de Lardizábal 5, 20018 San Sebastián, Spain.
 ⁶Instituto Nicolás Cabrera, Universidad Autónoma de Madrid, 28049 Madrid, Spain
 ⁷Condensed Matter Physics Center (IFIMAC), Universidad Autónoma de Madrid, 28049 Madrid, Spain

Methods

Sample preparation

Monolayers of NbSe₂ were grown on epitaxial bilayer graphene (BLG) on 6H-SiC(0001) by molecular beam epitaxy at a base pressure of $\sim 3 \cdot 10^{-10}$ mbar in our homemade UHV-MBE system at the DIPC in San Sebastian (Spain). SiC wafers with resistivities $\rho \sim 120 \ \Omega$ cm were used. Graphitization of the SiC surface was carried out using an automatized cycling mechanism where the sample was ramped between 700 °C and 1350 °C at a continuous ramping speed of $\sim 20^{\circ}$ C/s. The SiC crystal was kept for 30 s at 1350 °C for 80 cycles.

Reflective high energy diffraction (RHEED) was used to monitor the layer growth of NbSe₂. During the growth, the BLG/SiC substrate was kept at 570°C. High purity Nb (99.99%) and Se (99.999%) were evaporated using an electron beam evaporator and a standard Knudsen cell, respectively. The Nb:Se flux ratio was kept at 1:30, while evaporating the Se led to a pressure of $\sim 4 \cdot 10^{-9}$ mbar (Se atmosphere). Samples were prepared using an evaporation time of 30 min to obtain a coverage of $\sim 1-2$ ML. To minimize the presence of atomic defects, evaporation of Se was subsequently kept for additional 5 minutes. Atomic Force Microscopy at ambient conditions was routinely used to optimize the morphology of the NbSe₂ layers. The samples used for AFM characterization were not further used for STM.

Lastly, in order to transfer the samples from our MBE to Madrid for HAS measurements, they were capped with a ~ 10 nm film of Se. The capping layer was easily removed in the UHV-HAS system by annealing the sample at $\sim 300^{\circ}$ C.

HAS measurements

The single-layer NbSe₂ sample was mounted in the HAS chamber in Madrid and heated to 300°C in ultra-high vacuum (UHV) for an hour to desorb the Se capping layer. After cooling down, the crystalline quality of samples was revealed by the observation in HAS of high specular intensity and diffraction features, like the ones shown in Fig. S-1 below. The samples were characterized by a set of HAS and time-of-flight measurements which were conducted in the Surface Science Laboratory in Universidad Autónoma de Madrid. The experiments have been carried out in two different systems, both having UHV chambers with base pressures in the low 10^{-10} mbar range. The first system is a He-scattering apparatus in which the detector can rotate by 200° in the scattering plane, defined by the beam direction and the normal to the surface, and by +/-15° in the direction perpendicular to the scattering plane. This allows detection of both in-plane and out-of-plane intensities for fixed incident conditions. The He-diffraction measurements reported in the text have been performed using this system. The second chamber is a high-resolution He-scattering machine with a time-of-flight (TOF) arm and a fixed angle of

108° between the incident and outgoing beam. In both HAS machines, the He atom beam is produced by a free expansion of helium gas through a 10 μ m nozzle. The incident beam energy can be varied by changing the nozzle temperature. The sample can be heated by electronic bombardment or cooled with liquid nitrogen to 90K or liquid He (down to 40K). The sample can be moved in the X, Y and Z directions, rotated in the X-Y plane and changed the azimuthal angle (ϕ), which determines the incidence direction with respect to the lattice vector.



Figure SI-1. (a) Kinematics of elastic HAS in-plane and out-of-plane scattering, with \mathbf{k}_i and \mathbf{k}_f the incident and final He-atom wavevectors ($k_i = k_f$), θ_i and θ_f the incident and final polar angles, $\phi_i = 0$ and ϕ_f the incident and final azimuthal angles with respect to the Γ M direction of NbSe₂ (taken as the incident direction). \mathbf{K}_i and \mathbf{K}_f are the respective surface parallel components and $\Delta \mathbf{K} = \mathbf{K}_f - \mathbf{K}_i$. (b) 2D map of the moiré structure overserved on NbSe₂ with individual spectra collected performing scans along ϕ_f . (c) HAS diffraction spectra collected along ϕ_f and θ_f shown as vertical

and horizonal plots, respectively. Note that the maximum of the first order peak $(0\bar{1})$ appears at $\phi_i = 1^\circ$ (red vertical curve), due to azimuthal misalignment of the NbSe₂ lattice with respect to the sagittal plane $\phi_i = 0^\circ$. This offset can be traced back to a misalignment $\phi_i = 5^\circ$. (d) Calculated diffraction pattern of HAS from both the (1x1) NbSe₂ and $(3\sqrt{3}x3\sqrt{3})R30^\circ$ surfaces under the experimental conditions: $E_i = 44$ meV, $\phi_i = 5^\circ$ and $\theta_i = 60^\circ$. The measurements shown in b) and c) were done with a sample temperature of 40K.



Figure SI-2. In-plane (black curve) and out-of-plane (red curve) angular distributions of HAS measured along Γ M from the surface of NbSe₂ (0001). The angle of incidence is 60° and $E_i = 44$ meV. Triangles indicate the expected position of diffraction peaks for a lattice constant a=3.44 Å and $\phi_i = 1.5^\circ$ due to azimuthal misalignment of the crystal.